

IDS - 07/30/2013

**ELECTRONIC INFORMATION DISCLOSURE STATEMENT**

Electronic Version v18

Stylesheet Version v18.0

**Title of  
Invention****PROCESSES AND SYSTEMS FOR MAKING PHOSGENE**

Application Number :

Confirmation Number:

First Named Applicant: Frank Bagala

Attorney Docket Number: 131236-1

Art Unit:

Examiner:

Search string: ( 4556547 ).pn

**US Patent Documents****Note: Applicant is not required to submit a paper copy of cited US Patent Documents**

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
SH	1	4556547	1985-12-03	Nishino, et al.	A1	423	230

**Signature**

Examiner Name	Date
/Stuart Hendrickson/ (06/14/2006)	

<b>INFORMATION DISCLOSURE CITATION</b> <small>(Use several sheets if necessary)</small>				Docket Number (Optional) <b>131236-1</b>		Application Number <b>10/604,549</b>	
				Applicant(s) <b>Frank Bagala et al.</b>			
				Filing Date <b>July 30, 2003</b>		Group Art Unit <b>1754</b>	

  

U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

  

U.S. PATENT APPLICATION PUBLICATIONS							
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

  

FOREIGN PATENT DOCUMENTS								
	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
SH	1	EP 1112997 A2	04.07.2001	Europe	—	—		✓
SH	2	WO 02/08362 A1	31.01.2002	International	—	—		✓

  

OTHER DOCUMENTS			<small>(Including Author, Title, Date, Pertinent Pages, Etc.)</small>
SLH	3	Chemical Abstracts and Indexes, American Chemical Society, 02 July 1990, XP000063501, ISSN: 0009-2258; "Manufacture of High-Purity Phosgene Gas", Abstract Only, 1 page	
SLH	4	International Search Report, International Application No. PCT/US2004/023429; International Filing date: July 21, 2004; Date of Mailing: November 22, 2004; 6 pages	

  

EXAMINER    /Stuart Hendrickson/ (06/14/2006)	DATE CONSIDERED
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.